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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/421,043	10/20/1999	TOSHIO MASUDA	503.34403VP2	3576
20457	7590 07/26/2005		EXAMINER	
ANTONELLI, TERRY, STOUT & KRAUS, LLP			ALEJANDRO MULERO, LUZ L	
SUITE 1800	I SEVENTEENTH STRE	ET .	ART UNIT	PAPER NUMBER
ARLINGTON	N, VA 22209-3873		1763	

DATE MAILED: 07/26/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	09/421,043	MASUDA ET AL.	
Office Action Summary	Examiner	Art Unit	
	Luz L. Alejandro	1763	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet wi	th the correspondence addres	s
A SHORTENED STATUTORY PERIOD FOR RETHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, find the period for reply is specified above, the maximum statutory properties of the period for reply within the set or extended period for reply will, by some Any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b).	ON. R 1.136(a). In no event, however, may a ron. a reply within the statutory minimum of thirt eriod will apply and will expire SIX (6) MON statute, cause the application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this commu ANDONED (35 U.S.C. § 133).	nication.
Status			
1) Responsive to communication(s) filed on	29 April 2005.		
	This action is non-final.		
3) Since this application is in condition for all		ers, prosecution as to the me	rits is
closed in accordance with the practice und	•	•	
Disposition of Claims			
4)⊠ Claim(s) <u>78-89</u> is/are pending in the applic	ection		
4a) Of the above claim(s) is/are with			
5) Claim(s) is/are allowed.	idiami nom consideration.	•	
6) Claim(s) <u>78-89</u> is/are rejected.			•
7) Claim(s) is/are objected to.	•		
8) Claim(s) are subject to restriction a	nd/or election requirement.		
Application Papers			
9) The specification is objected to by the Exa	miner		
10) The drawing(s) filed on is/are: a)		hy the Examiner	
Applicant may not request that any objection to			
Replacement drawing sheet(s) including the ∞	= : :		121(d)
11) The oath or declaration is objected to by the			
,			
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docur 2. Certified copies of the priority docur 3. Copies of the certified copies of the application from the International Bu	nents have been received. nents have been received in A priority documents have been	pplication No	ge
* See the attached detailed Office action for a	•	received.	
Attachment(s)	•		
1) Notice of References Cited (PTO-892)		Summary (PTO-413)	
2) Notice of Draftsperson's Patent Drawing Review (PTO-94	"	s)/Mail Date nformal Patent Application (PTO-152)\
 Information Disclosure Statement(s) (PTO-1449 or PTO/S Paper No(s)/Mail Date 	B/08) 5) ☐ Notice of 1 6) ☐ Other:		-)

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 78-85 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsuji et al., JP 4-214873 in view of Shinji, JP 9-275092 and Ishioka, JP3-104222.

Tsuji et al. shows the invention substantially as claimed including a plasma apparatus for processing a sample 10 disposed inside a vacuum vessel, the apparatus comprising: a chamber located inside said vacuum vessel, an interior of the chamber being in a vacuum state and the sample being disposed in the chamber, wherein an electric field is supplied and processing gas is introduced to the chamber so as to generate the plasma in the chamber; an electrode 11 disposed at a lower part of the

chamber and having the sample loaded thereon so as to be processed by the plasma; a member 20 held on an inner surface of a side wall of the vacuum vessel and forming an inner surface of the chamber which is contact with the plasma generated in the chamber (see fig. 1); the member having a thermally conductive medium 21B supplied therein so as to circulate within the member; and a temperature controller to adjust the thermally conductive medium so as to adjust a temperature of a surface of the member so as to control the temperature of the member within a predetermined range, wherein the thermally conductive medium is a coolant (see, for example, paragraphs 0032 and fig. 1).

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Tsuji et al. does not expressly disclose that the member 20 is detachable and removable to the outside of the chamber. Shinji discloses a cylindrical plasma apparatus comprising a member 12 that is detachably attached to the chamber in order to be easily removable, therefore, reducing the cleaning time of the apparatus (see paragraph 0005). Also, Ishioka discloses a plasma apparatus comprising a removable shield 17 for enabling removing of the shield during maintenance and management of the system (see page 7-first paragraph, and fig. 2). Therefore, in view of these disclosures, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the apparatus of Tsuji et al. as to comprise a detachable member because in such a way maintenance and management of the apparatus is more easily performed, and the cleaning time of the apparatus is reduced.

With respect to claims 80 and 84 regarding the chamber being at least partially constituted by a sidewall which is grounded to earth, Shinji discloses that the plasma

chamber is grounded. It is also known in the art that electrical floating is prevented by grounding the chamber. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Tsuji et al. as to ground a sidewall of the chamber in order to prevent the chamber from being electrically floating, which can alter the process conditions, thereby, ensuring repeatability of the wafers being processed.

With respect to: a) the apparatus being a plasma etching apparatus, b) wherein the temperature controller adjusts the temperature of the surface of the member so as to enable a coating of etching reaction products generated in the chamber due to etching processing of the sample to be deposited on the member with substantially no peeling therein, c) wherein a temperature of the surface of the member is controlled within the claimed temperature range, and d) wherein a temperature of the surface of the member is controlled to be lower than a temperature of the sample during the etching processing of the sample, such limitations are directed to method limitations instead of apparatus limitations, and since an apparatus is being claimed as the instant invention, the method teachings are not considered to be the matter at hand, since a variety of methods can be done with the apparatus. The method limitations are viewed as intended uses that do not further limit, and therefore do not patentably distinguish the claimed invention. The apparatus of Tsuji et al. modified by Shinji and Ishioka is capable of being used for an etching process, of using the temperature controller to deposit products on the member with substantially no peeling, controlling the temperature of the surface of the member within the claimed temperature range, and

controlling the temperature of the surface of the member to be lower than the sample as claimed.

Claims 86-89 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsuji et al., JP 4-214873 in view of Shinji, JP 9-275092 and Ishioka, JP3-104222 as applied to claims 78-85 above, and further in view of Powell et al., U.S. Patent 4,971,653 or Kaneko et al., U.S. Patent 5,223,113.

Tsuji et al., Shinji, and Ishioka is applied as above but does not expressly disclose a sample temperature controller to adjust a temperature of the sample on the electrode.

Kaneko discloses a sample temperature controller (20,53,) to adjust a temperature of the substrate (see fig. 2 and its description). Alternatively, Kaneko et al. discloses a sample temperature controller 26 to adjust a temperature of the sample on the electrode (see fig. 1 and its description). In view of these disclosures, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Tsuji et al. modified by Shinji and Ishioka so as to include a temperature controller as suggested by Powell et al. and Kaneko et al. because in such a way the processing of the sample in the apparatus can be more tightly controlled.

Response to Arguments

Applicant's arguments filed 4/29/05 with respect to claims 78-89 have been fully considered but they are not persuasive.

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Applicant argues that the Tsuji et al. reference does not disclose coils which are disposed within the member 20. However, note from fig. 1 of Tsuji et al. that the coils are disposed within the confines of the member 20 and therefore the claims, when given their broadest reasonable interpretation, read on the invention as claimed. Concerning applicant's statement that the Tsuji et al., Shinji et al., and Ishioka references fail to show a temperature controller performing a process as claimed or a plasma etching process, such limitations are directed to method limitations instead of apparatus limitations, and since an apparatus is being claimed as the instant invention, the method teachings are not considered to be the matter at hand, since a variety of methods can be done with the apparatus. The method limitations are viewed as intended uses that do not further limit, and therefore do not patentably distinguish the claimed invention. The apparatus of Tsuji et al. modified by Shinji et al. or Ishioka are capable of being used for an etching process, and of using the temperature controller as claimed.

In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Furthermore, applicant argues that Shinji does not show a member detachably held on an inner surface of a side wall of the vacuum vessel. However, as clearly pointed out, the member 12 in Shinji is exchangeable and therefore detachable.

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In response to applicant's argument that the examiner's conclusion of obviousness is based upon improper hindsight reasoning, it must be recognized that any judgment on obviousness is in a sense necessarily a reconstruction based upon hindsight reasoning. But so long as it takes into account only knowledge which was within the level of ordinary skill at the time the claimed invention was made, and does not include knowledge gleaned only from the applicant's disclosure, such a reconstruction is proper. See *In re McLaughlin*, 443 F.2d 1392, 170 USPQ 209 (CCPA 1971).

With respect to: a) the apparatus being a plasma etching apparatus, b) wherein the temperature controller adjusts the temperature of the surface of the member so as to enable a coating of etching reaction products generated in the chamber due to etching processing of the sample to be deposited on the member with substantially no peeling therein, and c) controlling the temperature of the surface of the member as claimed, as stated in the above rejection, such limitations are directed to method limitations instead of apparatus limitations, and since an apparatus is being claimed as the instant invention, the method teachings are not considered to be the matter at hand, since a variety of methods can be done with the apparatus. The method limitations are viewed as intended uses that do not further limit, and therefore do not patentably distinguish the claimed invention. A recitation of the intended use of the claimed invention must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of performing the intended use, then it meets the claim.

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See *In re Casey*, 152 USPQ 235 (CCPA 1967) and *In re Otto*, 136 USPQ 458, 459 (CCPA 1963). The apparatus of Tsuji et al. modified by Shinji and Ishioka is capable of being used for an etching process, of using the temperature controller to deposit products on the member with substantially no peeling, and controlling the temperature of the surface of the member as claimed.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luz L. Alejandro whose telephone number is 571-272-

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1430. The examiner can normally be reached on Monday to Thursday from 7:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Luz L. Alejandro Primary Examiner Art Unit 1763

July 22, 2005